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FORM PTO-1449 (Modified)
LIST OF PATENTS AND PUBLICATIONS
FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT
(Use several sheets if necessary)
Sheet 1 of 1

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In the Application of Brennen et al.

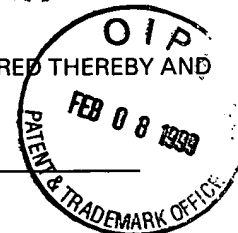
Serial No.: 09/233,694

Filed: January 19, 1999

Art Unit: ¹⁷⁵⁶ ~~Unassigned~~

Examiner: ^{Young} ~~Unassigned~~

Title: METHOD FOR PRODUCING HIGH-SURFACE AREA TEXTURING OF A SUBSTRATE, SUBSTRATES PREPARED THEREBY AND MASKS FOR USE THEREIN



U.S. PATENT DOCUMENTS

Exam. Init.	Ref. Desig.	Document No.	Date	Name	Class	Sub Class	Filing Date
<i>Cuy</i>	AA-1	4,478,677	Oct. 23, 1984	Chen et al.	—	—	
<i>4</i>	AB-1	4,490,210	Dec. 25, 1984	Chen et al.	—	—	
	AC-1	4,490,211	Dec. 25, 1984	Chen et al.	—	—	
	AD-1	4,923,772	May 8, 1990	Kirch et al.	430	5	
<i>4</i>	AE-1	5,500,071	Mar. 19, 1996	Kaltenbach et al.	—	—	
	AF-1	5,571,410	Nov. 5, 1996	Swedberg et al.	—	—	
<i>Cuy</i>	AG-1	5,658,413	Aug. 19, 1997	Kaltenbach et al.	—	—	

FOREIGN PATENT DOCUMENTS

Exam. Init.	Ref. Desig.	Document No.	Publication Date	Country or Patent Office	Class	Sub Class	Translation YES NO
<i>Cuy</i>	AH-1	7-241690	19 September 1995	Japan	—	—	X abstract only
<i>Cuy</i>	AI-1	7-80675	28 March 1995	Japan	—	—	X

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)

Exam. Init.	Ref. Desig.	Description
<i>Cuy</i>	AJ-1	Krajnovich et al., "Formation of 'Intrinsic' Surface Defects During 248 nm Photoablation of Polyimide," <i>J. Appl Phys.</i> 73 :3001-3008 (1993)

Examiner:

Date Considered:

EXAMINER: Initial if citation considered whether or not the citation conforms with MPEP609. Draw a line through the citation if not in conformance and not considered. Include copy of this form with next communication to applicant.